

Expert Report for Pat Sample



Focus

Styles

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About this Report

This report is based upon the Styles assessment, which explores an individual’s motives, preferences, needs and talents in critical work areas.

The results are presented on a 1 to 10 ‘Sten’ scale based on a comparison with a mixed occupational group.

Since the questionnaire is a self-report measure, the results reflect the individual’s self-perceptions. Nevertheless, our extensive research has shown it to be a valid measure of how people will operate in the workplace.

It should be remembered that the information contained in this report is potentially sensitive and every effort should be made to ensure that it is stored in a secure place.

The information contained within this report will provide an overview of the respondent’s motives, preferences, needs and talents at work for 12 to 24 months, depending upon circumstances.

The report was produced using Saville Consulting software systems. It has been derived from the results of a questionnaire completed by the respondent, and reflects the responses they made.

This report has been generated electronically. Saville Consulting do not guarantee that it has not been changed or edited. We can accept no liability for the consequences of the use of this report, howsoever arising.

The application of this questionnaire is limited to Saville Consulting employees, agents of Saville Consulting and clients authorized by Saville Consulting.

Introduction to Assessment Report

This report provides information on motives, preferences, needs and talents, based on Pat Sample's responses to the Styles questionnaire.

Overview

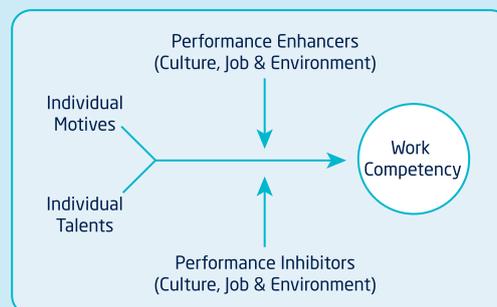
The overview page provides a summary of Pat Sample's responses on the Focus Styles questionnaire. The four indicators in the Response Summary check the validity of the profile and highlight extreme response patterns. The Profile Breakdown explains the aspects of the Psychometric Profile that are unique to Saville Consulting Wave.

Psychometric Profile

The Psychometric Profile shows the questionnaire results on the 12 Focus Styles sections, with three sections devoted to each of the four Saville Consulting Wave clusters Thought, Influence, Adaptability and Delivery. The 12 sections are each comprised of three underlying facets, verbal descriptions of which are provided under each section name. These vary according to the score on the individual facet. There are 36 facets in total.

Predicted Culture/Environment Fit

The Predicted Culture/Environment Fit Report gives an indication of the aspects of the culture, job and environment that are likely to enhance or inhibit a person's success. Saville Consulting's groundbreaking research suggests that people's motives and talents interact in important ways with culture, job and environment characteristics to help determine their work performance and competency.



Competency Potential Profile

The Competency Potential Profile is based on links established between the 36 facets of the Focus Styles questionnaire and independent assessments of work performance. Based on real data, this gives a unique prediction of Pat Sample's likely strengths and limitations in 12 key performance areas that are defined through the verbal descriptions of their underlying components. This prediction should be interpreted against key work requirements as established through job analysis or competency profiling methods. Highly positive profiles may reflect an unrealistically positive self-view while low scoring profiles may reflect an overly critical self-view. In such cases, it is particularly important to verify the results against other information.

Overview

The Response Summary provides an overview of Pat Sample's responses to the Focus Styles questionnaire through four indicators. The pattern of responses should be kept in mind when interpreting the Psychometric Profile.

Response Summary

	1	2	3	4	5	6	7	8	9	10
Ratings Acquiescence Overall, more positive in self-ratings than many people								■		
Consistency of Rankings Reasonably consistent in rank ordering of characteristics						■				
Normative-Ipsative Agreement Overall, the degree of alignment between normative and ipsative scores is slightly less than for most people		■								
Motive-Talent Agreement Overall, the degree of alignment between Motive and Talent scores is slightly less than for most people			■							

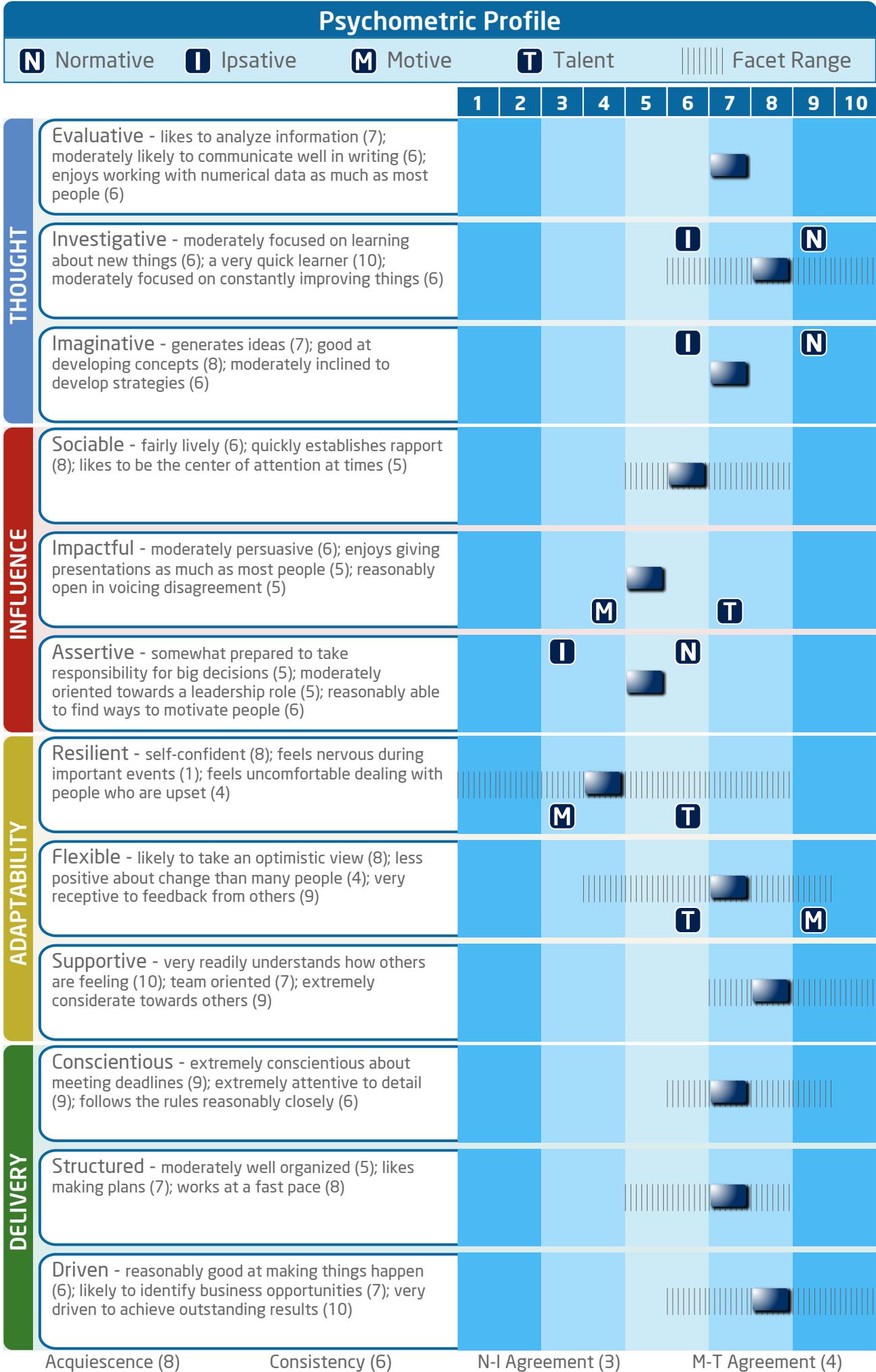
Profile Breakdown

The Profile Breakdown explains the Facet Range, Motive-Talent Split and Normative-Ipsative Split features that are unique to Saville Consulting Wave reporting.

Facet Range. Where the range of facet scores within any section is of 3 stens or more, this is indicated both by hatching on the section scale and the provision of individual facet scores in brackets alongside each verbal facet description.

Normative-Ipsative Split. Differences between Normative (rating) and Ipsative (ranking) scores of 3 stens or more on a given section are indicated by the markers **N** and **I**, respectively. Where Ipsative scores are higher than Normative ones, the person may have been overly self critical in their normative self descriptions. If normative scores are higher than ipsative, it may mean that the person has been less self critical and has possibly exaggerated their normative description. This provides specific areas for further verification, rather than one unspecified measure of social desirability.

Motive-Talent Split. Differences between Motive and Talent scores of 3 stens or more on a given section are indicated by the markers **M** and **T**, respectively. Such differences may suggest an incentive to develop in given areas, or indicate areas where environmental influences are having a strong impact.



Predicted Culture/Environment Fit

Based on extensive Saville Consulting people and culture audit data, this report highlights the aspects of the culture, job and environment that are likely to enhance or inhibit Pat Sample's success:

Performance Enhancers

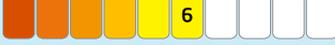
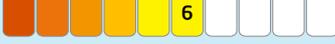
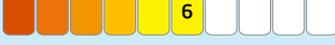
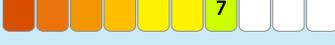
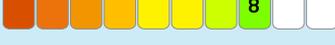
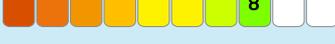
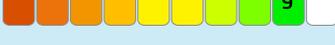
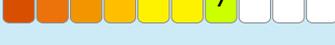
- ⊕ where there are high ethical standards and people behave with integrity and discretion
- ⊕ where honest feedback is encouraged and freely given
- ⊕ where there are numerous opportunities for learning and extending one's range of knowledge and skills
- ⊕ where importance is attached to punctuality, and completing tasks to deadline and reliability is clearly valued
- ⊕ where there is an atmosphere of mutual trust, there is a high degree of tolerance and people are considerate in their behavior towards others
- ⊕ where there is constantly a lot on the go, people are engaged in multiple tasks and efficient use of time is important
- ⊕ where there is a strong results focus and determination to succeed, no matter what, and people are rewarded for achieving outstanding results
- ⊕ where creativity and innovation are encouraged, and radical ideas and solutions welcomed

Performance Inhibitors

- ⊖ where unethical practices are condoned and people are required to compromise on their principles
- ⊖ where feedback is discouraged and seldom given
- ⊖ where opportunities for acquiring new skills and extending one's range of knowledge are severely restricted
- ⊖ where there is a culture that allows deadlines to be passed and tasks are often left unfinished
- ⊖ where people are distrustful of each other, there is a lack of tolerance and a lack of consideration for others
- ⊖ where the pace of work is leisurely, there is little multi-tasking and time is not used efficiently
- ⊖ where the urge to achieve outstanding results is not great and people seldom persist in the face of difficulties
- ⊖ where conventional attitudes prevail, traditional approaches are preferred and people are discouraged from generating new ideas

Competency Potential Profile

The following report summarizes Pat Sample's areas of greater and lesser potential based on Saville Consulting's extensive international database linking Focus Styles to work performance.

	Competency Description	Potential
SOLVING PROBLEMS	Evaluating Problems Examining Information; Documenting Facts; Interpreting Data	 Fairly High higher potential than about 75% of professionals
	Investigating Issues Developing Expertise; Adopting Practical Approaches; Providing Insights	 Fairly High higher potential than about 75% of professionals
	Creating Innovation Generating Ideas; Exploring Possibilities; Developing Strategies	 Fairly High higher potential than about 75% of professionals
INFLUENCING PEOPLE	Building Relationships Interacting with People; Establishing Rapport; Impressing People	 Above Average higher potential than about 60% of professionals
	Communicating Information Convincing People; Articulating Information; Challenging Ideas	 Above Average higher potential than about 60% of professionals
	Providing Leadership Making Decisions; Directing People; Empowering Individuals	 Above Average higher potential than about 60% of professionals
ADAPTING APPROACHES	Showing Resilience Conveying Self-confidence; Showing Composure; Resolving Conflict	 Below Average higher potential than about 40% of professionals
	Adjusting to Change Thinking Positively; Embracing Change; Inviting Feedback	 Fairly High higher potential than about 75% of professionals
	Giving Support Understanding People; Team Working; Valuing Individuals	 High higher potential than about 90% of professionals
DELIVERING RESULTS	Processing Details Meeting Timescales; Checking Things; Following Procedures	 High higher potential than about 90% of professionals
	Structuring Tasks Managing Tasks; Upholding Standards; Completing Tasks	 Very High higher potential than about 95% of professionals
	Driving Success Taking Action; Seizing Opportunities; Pursuing Goals	 Fairly High higher potential than about 75% of professionals